

SECTION C — CHEMISTRY; METALLURGY

C25 ELECTROLYTIC OR ELECTROPHORETIC PROCESSES; APPARATUS THEREFOR

C25F PROCESSES FOR THE ELECTROLYTIC REMOVAL OF MATERIALS FROM OBJECTS; APPARATUS THEREFOR (treatment of water, waste water or sewage by electrochemical methods C02F 1/46; anodic or cathodic protection C23F 13/00) [2]

Note(s) [2]

In this subclass, the last place priority rule is applied, i.e. at each hierarchical level, in the absence of an indication to the contrary, classification is made in the last appropriate place.

1/00 Electrolytic cleaning, degreasing, pickling, or descaling [2, 2006.01]

1/02 • Pickling; Descaling [2, 2006.01]

1/04 • • in solution [2, 2006.01]

1/06 • • • of iron or steel [2, 2006.01]

1/08 • • • of refractory metals [2, 2006.01]

1/10 • • • of actinides [2, 2006.01]

1/12 • • in melts [2, 2006.01]

1/14 • • • of iron or steel [2, 2006.01]

1/16 • • • of refractory metals [2, 2006.01]

1/18 • • • of actinides [2, 2006.01]

3/00 Electrolytic etching or polishing [2, 2006.01]

3/02 • Etching [2, 2006.01]

3/04 • • of light metals [2, 2006.01]

3/06 • • of iron or steel [2, 2006.01]

3/08 • • of refractory metals [2, 2006.01]

3/10 • • of actinides [2, 2006.01]

3/12 • • of semiconducting materials [2, 2006.01]

3/14 • • locally [2, 2006.01]

3/16 • Polishing [2, 2006.01]

3/18 • • of light metals [2, 2006.01]

3/20 • • • of aluminium [2, 2006.01]

3/22 • • of heavy metals [2, 2006.01]

3/24 • • • of iron or steel [2, 2006.01]

3/26 • • • of refractory metals [2, 2006.01]

3/28 • • • of actinides [2, 2006.01]

3/30 • • of semiconducting materials [2, 2006.01]

5/00 Electrolytic stripping of metallic layers or coatings [2, 2006.01]

7/00 Constructional parts, or assemblies thereof, of cells for electrolytic removal of material from objects (for both electrolytic coating and removal C25D 17/00); Servicing or operating [2, 2006.01]

7/02 • Regeneration of process liquids [2, 2006.01]